











































## Thin film YIG

- Numerous Growth techniques
- RF sputtered followed by anneal 850c for
- Grow on GGG (Gd<sub>3</sub>Ga<sub>5</sub>O<sub>12</sub>)
- 0.06% lattice mismatch
- SuperSTEM
  - Abberation corrected
  - HAADF
  - 6nm diffusion
  - Diffusion co-efficient 1x10<sup>-17</sup>cm<sup>2</sup>s<sup>-1</sup> (agrees with bulk)















































































## Thin film Er

















